

ABSTRACT**Method for removing a metal deposit placed on a surface in a chamber**

The invention relates to a method for removing a metallic deposit disposed on a surface in a chamber, said method comprising the following steps:

- a) a step of oxidizing the metallic deposit;
- b) a step of injecting chemical species adapted to volatilized the oxidized metallic deposit, said step b) being implemented during at least a part of step a);

said removal method being characterized in that in step b), the chemical species are injected according to a sequence of pulses.

Figure 2